

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant : Washio et al.
Appl. No. : 10/561,802
Filed : December 22, 2005
For : DEVELOPER COMPOSITION
FOR RESISTS AND METHOD
FOR FORMATION OF RESIST
PATTERN
Examiner : Le, Hoa Van
Group Art Unit : 1752

RESPONSE TO OFFICE ACTION

Mail Stop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

In response to the Office Action mailed **September 25, 2006**, Applicants respectfully request consideration of the following amendments and remarks:

Amendments to the Claims are reflected in the listing of claims which begins on page 2 of this paper.

Remarks/Arguments begin on page 3 of this paper.